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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/542,123	12/09/2005	Vladimir Pavlovich Popov	U 015850-2	U 015850-2 8400	
140	7590 06/21/2007		EXAM	INER	
LADAS & PARRY 26 WEST 61ST STREET			JEFFERSON, QUOVAUNDA		
NEW YORK, NY 10023			ART UNIT	PAPER NUMBER	
			2823	<del></del>	
			MAIL DATE	DELIVERY MODE	
			06/21/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)				
Office As Comment	10/542,123	POPOV ET AL.				
Office Action Summary	Examiner	Art Unit				
	Quovaunda Jefferson	2823				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING D.  - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period to Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATIO 36(a). In no event, however, may a reply be till will apply and will expire SIX (6) MONTHS from 5, cause the application to become ABANDONE	N. mely filed n the mailing date of this communication. ≣D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 13 A	pril 2007.					
•	· ·					
•—	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under b	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
4)⊠ Claim(s) <u>1-11</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdra	4a) Of the above claim(s) is/are withdrawn from consideration.					
5) Claim(s) is/are allowed.						
6)⊠ Claim(s) 1-11 is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/o	8) Claim(s) are subject to restriction and/or election requirement.					
Application Papers						
9) The specification is objected to by the Examiner.						
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) All b) Some * c) None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
3. Copies of the certified copies of the priority documents have been received in this National Stage						
application from the International Bureau (PCT Rule 17.2(a)).						
* See the attached detailed Office action for a list of the certified copies not received.						
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Attachment(s)						
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date						
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08)	5) Notice of Informal					
Paper No(s)/Mail Date 6) Other:						

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### **DETAILED ACTION**

## Claim Rejections - 35 USC § 112

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claims 1-11 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The term "low vacuum" in claims 1, and 9-11 and the specification is a relative term, which renders the claim indefinite. The term "low vacuum" is not defined by the claim, the specification does not provide a standard for ascertaining the requisite degree, and one of ordinary skill in the art would not be reasonably apprised of the scope of the invention.

The use of the term "low vacuum" is a redundant term, as it is well known in the art that a vacuum has a gaseous pressure that is lower than atmospheric pressure. Changing this term either a "low pressure" or "vacuum" is suggested.

Claim 1 recites the limitation that "the joining and splicing of the wafer and substrate along the implanted hydrogen is carried out....such that he implanted

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hydrogen stays mostly bound". Examiner is unsure as to what this pertains because once the implanted layer is exfoliated, the implanted hydrogen is not bound in the wafer or substrate layer, but instead, is released and added to the atmosphere. An appropriate correction should be made.

## Allowable Subject Matter

Claims 1-11 would be allowable if rewritten or amended to overcome the rejection(s) under 35 U.S.C. 112, 2nd paragraph, set forth in this Office action.

Regarding claim 1, prior art fails to teach the joining and splicing of the wafer and substrate and exfoliating along the layer of implanted hydrogen is carried out at a low vacuum and a second moderate temperature.

#### Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. US Patent 6,136,666, issued to So, discloses method for fabricating silicon-on-insulator wafer. US Patent 6,066,571, issued to Usuda et al, discloses method of preparing semiconductor surface. US Patent 5,755,914, issued to Yonehara, discloses method for bonding semiconductor substrates. US Patent 6,143,629, issued to Sato, discloses process for producing semiconductor substrate.

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US Patent 6,159,824, issued to Henley et at, discloses silicon-on-silicon wafer bonding process using a thin film blister-separation method. US Patent 6,251,754, issued to Oshima et al, discloses semiconductor substrate and manufacturing method using ion implantation. US Patent 6,191,007, issued to Matsui, discloses method for manufacturing a semiconductor substrate.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Quovaunda Jefferson whose telephone number is 571-272-5051. The examiner can normally be reached on Monday through Friday, 7AM to 3:30PM EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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> FERNANDO L. TOLEDO PRIMARY PATENT EXAMINER